0 3 2003 FORM PTO-1083 T. HATTORI et al RE application of Serial No.: 10/026,973

PATENT

Case Docket No.

T&A-109

Group Art Unit:

Filed: December 27, 2001

Examiner:

S. Rosasco

1756

RECEIVED SEP OS 2003 TO 170 For: A PHOTOMASK, THE MANUFACTURING METHOD, A PATTERNING METHOD AND A SEMICONDUCTOR DEVICE MANUFACTURING METHOD

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Transmitted herewith is an Amendment in the above-identified application.

Small entity status of this application under 37 CFR 1.9 and 1.27 has been established by a verified statement previously submitted.

A verified statement to establish small entity status under 37 CFR 1.9 and 1.27 is enclosed.

No additional fee is required.

The fee has been calculated as shown below:

(COL. 1)				(C	(COL. 2)		(COL. 3)	
	Re	Claims emaining After mendment		Pre	Highest No. Previously Paid For		Present Extra	
Total		14	Minus	••	20	=	0	
Indep.	·	1	Minus	•••	3	T=	0	
Firs	t Prese	entation of N	Aultiple De	nendent i	Claims			

Rate	Additional Fee
× 9	\$
× 42	\$
+ 140	\$
Total	\$

SMALL ENTITY

OR

OR

OTHER THAN A SMALL ENTITY

Rate	Additional Fee	
× 18	\$	0
× 84	\$	0
+ 280	\$	0
Total	\$	0

If the entry in Col. 1 is less than the entry in Col. 2, write '0' in Col. 3.

If the 'Highest Number Previously Paid For' IN THIS SPACE is less than 20, write '20' in this space.

If the 'Highest Number Previously Paid For' IN THIS SPACE is less than 3, write '3' in this space.

The 'Highest Number Previously Paid For' (Total or Independent) is the highest number found from the equivalent box in Col. 1 of a prior Amendment or the number of claims originally filed.

	Please charge my Deposit Account No. 50-1417 in the amount of \$				
	A check in the amount of \$ is attached in payment of:				
х	The Commissioner is hereby authorized to charge payment of the following fees associated or credit any overpayment to Deposit Account No. 50-1417.				

Any filing fees under 37 CFR 1.16 for the presentation of extra claims.

Any patent application processing fees under 37 CFR 1.17.

Х Any Extension of Time fees that are necessary, which are hereby requested if necessa

MATTINGLY, STANGER & MALUR, P.C. 1800 Diagonal Rd., Suite 370 Alexandria, Virginia 22314 (703) 684-1120

Date: September 2, 2003

. Stanger Registration No. 32,846

Attorney for Applicant(s)

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

T. HATTORI et al

Serial No. 10/026,973

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For: A PHOTOMASK, THE MANUFACTURING METHOD, A PATTERNING

METHOD, AND A SEMICONDUCTOR DEVICE MANUFACTURING METHOD

REPLY

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

September 2, 2003

Sir:

In reply to the Office Action mailed March 14, 2003, please amend the above-identified application as follows.